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Time-of-flight secondary ion mass spectrometry in the helium ion microscope

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Abstract

A helium ion microscope, known for high resolution imaging and modification with helium or neon ions, has been equipped with a time-of-flight spectrometer for compositional analysis. Here we report on its design, implementation and show first results of this powerful add-on. Our design considerations were based on the results of detailed ion collision cascade simulations that focus on the physically achievable resolution for various detection limits. Different secondary ion extraction geometries and spectrometer types are considered and compared with respect to the demands and limitations of the microscope. As a result the development and evaluation of a secondary ion extraction optics and time-of-flight spectrometer that allows the parallel measurement of all secondary ion masses is reported. First experimental results demonstrate an excellent mass resolution as well as high-resolution secondary ion imaging capabilities with sub-8 nm lateral resolution. The combination of high resolution secondary electron images and mass-separated sputtered ion distributions have a high potential to answer open questions in microbiology, cell biology, earth sciences and materials research.

Keywords: helium ion microscope, time-of-flight, elemental analysis, secondary ion mass spectrometry, high resolution imaging

1. Introduction

Secondary ion mass spectrometry (SIMS) instruments are commonly optimized for mass resolution, high yields of large molecules or fast sample throughput while high lateral resolution was only of secondary importance for most designs using a magnetic sector [1–4] as well as for time-of-flight (TOF) instruments [5–7]. To achieve highest positive ion yields typically cesium ions are used as primary particles, while a maximum number of negatively charged secondary ions is achieved by utilizing oxygen ions. Commercially available SIMS instruments can reach spot sizes below 50 nm [8] using cesium, gold or bismuth ions [9–11]. Bismuth and gallium ion beams from liquid metal ion sources can be focused down to perform SIMS with 20 nm resolution [11–16].

In terms of spatial resolution the existing approaches are limited not by the physical extent of the collision cascade but by the relatively large beam diameter. To achieve the highest possible spatial resolution in SIMS the beam diameter has to be sufficiently smaller than the area that secondary ions are sputtered from. The latter is related to the size of the collision cascade and depends on the primary ion species and energy as well as on the target material.

A helium ion microscope (HIM), equipped with a gas field ion source supplying 30 keV helium or neon ions with an extremely high brightness of up to $10^9 \text{A cm}^{-2} \text{sr}^{-1}$, is capable of surface-sensitive imaging with a lateral resolution of 0.5 nm [17–20]. Ion beam milling can be done with 1.8 nm resolution using neon and with 1.3 nm resolution using helium.
ions [21]. It currently provides the smallest beam diameter for both imaging and sputtering and as such would be the ideal candidate for high lateral resolution SIMS imaging. With respect to the implementation of SIMS in the HIM, the secondary ion yield for typical beam parameters [22, 23], possible ion extraction geometries [24] and the expected intermixing of layered structures [25] have been studied in previous work. Recently, TOF spectrometry has been implemented in the HIM to measure the energy of backscattered particles [26–28]. In these studies also the first proof of principle experiments on mass spectrometry of sputtered particles have been demonstrated.

An alternative and more sophisticated SIMS setup inside a HIM including an ion extraction optics and a modified Mattaeu-Herzog magnetic sector was recently presented by Wirtz et al. [29–31]. A mass resolution $m/\Delta m$ of up to 300 and a lateral resolution of $(10.0 \pm 3.6) \text{ nm}$ for $^7\text{Li}$ (75% to 25%) were demonstrated. However, the current implementation of this device is limited by the finite number of detectors and therefore masses that can be detected simultaneously [31]. The setup presented in this work demonstrates lateral highly resolved material analysis with TOF-SIMS in a HIM, that can detect all masses in parallel. In the literature different definitions of the lateral resolution have been used. Since Wirtz et al. demonstrated the highest lateral resolution so far, we used the same criteria for better comparability (75% to 25%). A comparison of different criteria and peak shapes as well as conversion factors has been published by Saeh [32].

2. Instrument Design

2.1. Theoretical considerations

In commercial SIMS machines the primary ion beam spot size typically exceeds the dimensions of the ions collision cascade. Contrary, in the HIM multiple scattered neon or helium projectiles and recoils will create sputtered particles within an area larger than the sub-nm beam spot. We performed binary collision approximation simulations with TRIM and evaluated the spatial origin of sputtered particles. The functions of lateral resolution are shown for example in Fig. 1 for 30 keV helium and neon ions impinging on amorphous silicon. The normalized sputter yield per area is plotted versus the distance from the point of impact for 30 keV helium and neon ions in silicon. Emission radii for 50% and 0.1% of the signal intensity are indicated by dashed arrows. The corresponding two-dimensional intensity profiles are shown beside in true dimensions according to the x-axis.

Figure 1: Simulated intensity profiles of sputtered particles in dependence on the distance from the point of impact for 30 keV helium and neon ions in silicon. Emission radii for 50% and 0.1% of the signal intensity are indicated by dashed arrows. The corresponding two-dimensional intensity profiles are shown beside in true dimensions according to the x-axis.

2 nm for helium and 1
4 nm for neon. Hence, a diameter of 2.4 nm for helium and 2.9 nm for neon approximate the fundamental achievable lateral resolution for imaging of flat surfaces with SIMS. Other target materials of course show slightly different values. The total ion range decreases for lower primary ion energies and for projectiles with higher atomic number. However, the cross section for nuclear collisions and the probability for multiple scattered particles increases at the same time. Therefore, the size and especially the shape of the intensity profile of sputtered particles depend on multiple parameters.

In the surrounding area of a pure occurrence of a material, the sensitivity for low concentration is degraded because of the long tails of the lateral resolution function. A small but not negligible fraction of the primary ion beam can cause sputtering of surface material in a distance of up to several 10 nm.

For example the sputtering yield drops to 0.1% in a distance of 8.7 nm from the primary ion impact for helium and 17.4 nm for neon.

An alternative resolution criteria can be given by the diameter that contains 50% of all sputtered particles and has been simulated by Wirtz et al. [35] to be 3 nm for 30 keV He and 9 nm for 30 keV Ne.
cording to the TRI3DST [33, 34] simulations used in this work 50% of all sputtered particles originate from a diameter of 3.6 nm for 30 keV He and 5.9 nm for 30 keV Ne in silicon, respectively. The values are in good agreement for helium but slightly differ for neon projectiles. It has been shown that binary collision approximation simulations deliver similar results as molecular dynamic simulations [36] and experimental data [37]. However, for the prediction of more accurate secondary ion yields especially for non-flat surfaces, three dimensional nanometer sized objects [38] or edge profiles, one has to consider the individual sample geometry, the bulk versus the surface composition, the crystalline structure, as well as ion induced heating effects in more advanced simulations. As SIMS can only deal with secondary ions one has to include the charge exchange processes at the surface in addition to the above listed points.

However, the charge exchange process of sputtered particles at the surface is difficult to predict.

For the detection of trace elements in the sample, the achievable lateral resolution is further limited by the finite number of atoms in the interaction volume and the related small number of sputtered ions [22]. Given the small likelihood for a sputtered sample atom to be charged (∼10⁻⁴) one has to remove approximately 250 nm³ of material to obtain a single secondary ion on average. Furthermore, the depth resolution in the interaction volume will suffer from ion beam damage and mixing [39–41]. Consequently, to maintain low detection limits with shrinking object dimensions, maximization of the extraction and detection efficiencies must be major design considerations. The use of oxygen or cesium primary particles to increase the positive or negative ion yields is unfortunately not an option as the microscope has so far only been designed by the manufacturer for the use of helium and neon gas. However, it has been shown that a gas field ion source can also be operated with other gases like hydrogen [42, 43], nitrogen [43, 44], oxygen [43] or xenon [45]. These ion species could offer many advantages for SIMS and their use will be subject of future investigations. The secondary ion yield can also be enhanced by oxygen gas flooding or cesium coating while using the highly focused Ne or He beam for sputtering [22, 23, 46].

### 2.2. Selection of mass spectrometer

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to less than one primary ion during the maximum flight-time interval. In another approach the measurement can be started by secondary electrons that are emitted when secondary particles are transmitted through a thin carbon foil [50]. That allows in comparison to the previous approach to increase the primary current until one secondary ion is extracted per maximum flight-time interval. Unfortunately, the efficiency and energy resolution of this type of spectrometer are rather low for keV particles making this approach not suitable to be applied in the HIM [51].

Alternatively, the time measurement can be triggered by pulsing the primary or extracted ions [9]. In comparison to the latter approach the beam current does not have to be reduced and an ion pulse can contain a large number of particles. The pulsed extraction of secondary ions was not considered for the discussed application due to less sensitivity since the primary ion beam would also cause sample damage when particles are extracted.

Consequently, the pulsing of the primary ion beam deflects them towards a detector. The sample is negative as the most gentle approach was recently implemented or positive biased relative to the extraction system in the HIM [26, 28] to enable backscattering spectrometry and SIMS as well. Initially, all primary ions can be deflected into a Faraday cup using the existing blanking plates in the HIM. That prevents the ions from leaving the primary column, hitting the sample surface and thus the creation of secondary particles.

Lowering of the blanking voltages to ground potential for a short time window allows primary ions to pass the beam blanker until the blanking voltages are applied again. The time difference between triggering the opening of the beam blanker and the moment when primary ions hit the sample surface is almost constant because of the sharp primary energy [18] and constant propagation times of signals in cables and electronics. Photons that can be created by the primary ion impact can be used to calculate this time difference with the accuracy of the distance between sample and stop detector due to known speed of light [26]. If no photons are available, the time between sample surface and the opening of the extraction nozzle. A large distance between the sample calibration. The spectrometer then just requires a flight tube, a detector at the end and electronics to determine the time difference. For mass spectrometers, the secondary ions have to be accelerated and extracted from the surface in order to obtain a sufficient 293 items outer dimension would allow the nozzle to be
inserted below the primary column and reduce the extraction distance and the primary beam degradation significantly. Therefore, the tilted straight extraction system was selected as the most suitable geometry for the TOF spectrometer. In both designs, the electrostatic sector as well as in the tilted straight extraction geometry, the primary beam has to be post-aligned in the extraction field.

The three major requirements for the extraction optics are: (1) a full angular collection meaning that secondary ions emitted in all direction are collected, (2) a low working distance, and (3) a high transmission. Secondary goals in the design process include a narrow extracted ion beam, high mass resolution. The simulation result which revealed the best overall SIMS extraction performance based on parameter-sets with a total of $10^5$ different parameter-sets with a total of $10^5$ different parameters, can help to find a solution that satisfies the high demands. We developed and applied an evolutionary algorithm to evaluate over $2 \times 10^5$ different parameter-sets with a total of $10^8$ simulated ion trajectories. The simulation result which revealed the best overall SIMS extraction performance based on just one single accelerating einzel lens is shown in Fig. 2.

A decelerating einzel lens would cause a higher flight time broadening because secondary ions would be slowed down closer to their initial sputter energy, corresponding to larger relative velocity difference. The sample, positioned at a still acceptable working distance of less than 12 mm, has to be tilted towards the extraction nozzle and biased to $\pm 500 \text{ V}$. Trajectories follow symmetrical lines around the extraction axis and the majority of the ions are focused to the end of the flight path. A fine grid at the nozzle entrance ensures straight field lines and avoids a divergent lens effect when ions enter the extraction. The additionally, electrostatic steering plates for fine alignment are integrated in the final design. A rendering of the overall setup is shown in Fig. 3. The extraction nozzle is fully retractable and can be aligned mechanically by micrometer calipers on the outside of the microscope. All parts facing the inside of the measurement chamber are at ground potential and should therefore not influence the microscope performance.

3. Results and discussion

3.1. Mass Spectra

In order to evaluate and calibrate the setup, various well characterized samples have been analyzed. From more than twenty (known) mass peaks the time-of-flight to mass calibration was derived. The calibrated mass spectra have been rebinned to an equal bin width. A positive ion mass spectrum of a silicon surface is shown as an example in Fig. 4. A primary beam of 25 keV Ne$^+$ with a current of 10 pA was utilized to obtain a high sputter yield while having a reasonable ion beam spot size. For the used repetition rate of 10 kHz this results in an effective current of approximately 3 fA. As described earlier, longer pulse widths can be applied to reduce the measurement time when mass resolution is less important. Short ion pulses can also cause a broadening of the primary ion beam [27]. For SIMS imaging with highest lateral resolution, a pulse width longer than 100 ns should be applied to minimize this broadening effect. Besides both silver isotopes, typical organic molecular fragments such as CH$_3^+$ and C$_4$H$_7^+$ with several intermediates and traces of sodium and hydrogen show...
Figure 2: Ion optical simulation of the secondary ion extraction system. Tilted sample is aligned with the y-axis, primary ions incident on the origin of ordiates and create 5000 secondary ions with an initial energy and angular distribution of the sputtered particles. Secondary particle density is calculated and shown on a logarithmic scale.

Figure 3: Scheme of primary ion column, sample holder and sectional view of the secondary ion extraction system. Primary ion beam in red, extracted secondary ions in green, electrical isolators white and ion optical elements copper-coloured.

Peaks below \( m/q = 80 \) u show a mean width of \( (0.26 \pm 0.09) \) u. At these masses, the resolution is sufficient for isotope separation which could be of particular interest in applications like isotope labeling in life science. In all measured spectra the peaks originating from bulk elements are far more broadened than the finite mass resolution of the spectrometer and show an asymmetric peak broadening towards shorter flight times or respectively lower masses. The \( ^{107}\text{Ag}^+ \) peak has full width at half maximum \( \Delta m \) of 1.68 u and the \( ^{109}\text{Ag}^+ \) has a \( \Delta m \) of 1.56 u.

In order to understand the origin of this broadening we simulated the energy and angular distribution of sputtered silver particles. The initial energy distribution of all sputtered particles before extraction has been simulated with TRI3DST [33, 34] (Fig. 5(a) blue). The relative large amount of sputtered particles with energies above 10 eV can be assigned to nuclear collisions with a relatively high energy transfer either with backscattered primary ions or recoils. These scattering events most probably take place below the first monolayers and would therefore in literature be referred as recoils.

Further, the binary collision approximation code is not able to provide the charge state of sputtered particles. The ionization probability of sputtered particles should in general increase towards higher energies [54–56]. For energies below 5 eV or inverse velocities above 5 \( \mu \)s/cm the secondary ion formation is still subject of current research [57, 58]. We did not include the charge state in our simulations since the theoretical models still deviate from the rare experimental data.

The efficiency (extraction and transmission) of the ion extraction system for sputtered particles has been simulated in ion beam transport calculations using IBSimu [53] (Fig. 5(a) green). Since the extraction system was designed to extract secondary ions with energies up to 10 eV, the loss of efficiency at
Figure 4: Positive ion mass spectrum of a silver surface (black). Primary beam: 25 keV Ne⁺, 30 ns pulse length, 10 kHz repetition rate, 3 fA effective current, $3 \times 10^{12}$ ions cm⁻².

Figure 5: (a) Normalized energy distribution of sputtered Ag particles from TRI3DST summed up over all sputtering angles (blue). Extracted and transmitted particles (orange) according to ion transport simulations using IBSimu [53] and derived efficiency of the SIMS extraction optics (green). (b) Corresponding mass spectra of the initial (blue) and extracted, transmitted silver particle distribution (orange). In comparison the experimental Ag spectrum (black).

Higher energies is attributed to insufficient focusing of the einzel lens. The gentle drop of intensities towards higher energies can be explained since a portion of sputtered ions are emitted perpendicular to the surface and straight into the extraction system and therefore do not have to be focused by the ion optics. The resulting energy distribution of extracted sputtered particles is shown in Fig. 5(a) (orange line). By comparing initial and extracted intensity we get a theoretical total efficiency of $(60 \pm 1)$% assuming the energetic and angular distribution extracted from TR3DST simulations. The total efficiency for sputtered positive or negative ions can be different from the time to mass calibration a sharp sputtering energy of 3 eV and a fixed flight path was assumed, these de-
3.2. Imaging SIMS

Besides the analysis of the composition for a certain object of interest, SIMS can be utilized to generate element distribution maps on a very small lateral scale. In this mode, instead of the evaluation of the observed peak broadening. The initial energy distribution from TRIO DST has been converted, rebinned and adjusted to the measured signal intensity for both silver isotopes assuming a natural isotope ratio (see Fig. 5(b) in blue). The same has been applied to the data corresponding to the orange line in Fig. 5(b).

The discrepancy between experimental data and simulation results (black and orange line in Fig. 5(b)) according to the above considerations may be attributed to the neglected dependence of the secondary particles charge state on their energy and angle of emission. Another explanation could be misalignment of the extraction optics or ion optical elements which were not considered in the simulation. If a particular charge fraction function of sputtered particles would be known and considered in the above simulations, the simulated and experimental data would be in better agreement. However, the charge fraction as a function of ion energy and emission angle is not available from literature in the energy range applied in this work.

Contrary to the bulk signal, the molecular fragments exclusively originate from the first atomic layers and a high energy transfer scattering event is unlikely. Those particles can be emitted in a rather soft collision in the recoil cascade and therefore have a narrower energy distribution. A high energy collision would also result in higher fragmentation of these molecular fragments.

The mass resolution for bulk components can be increased by using a higher acceleration voltage for the secondary ions to reduce the relative ion energy spread. However, this would require a custom sample holder that can be biased to more than ±500 V.

Alternatively, one could use a conventional reflection TOF design to compensate for the energy spread of sputtered particles. The latter would also result in a higher time or mass resolution due to the extension of the TOF. Therefore, the current setup was designed in a way that a later integration of a reflectron optics is easily possible.

Examples for both imaging modes are shown in Fig. 6 for two different samples. A copper transmission electron microscopy grid on top of copper scotch tape Fig. 6(a-c) and a NaCl micro and nanocrystal on a silicon substrate Fig. 6(e-i). Table salt was crushed on a silicon substrate to get micrometer and nanometer sized crystals of NaCl. It provides a sample with high yield of positive sodium and negative chlorine ions that is easy to obtain and prepare to reproduce the shown results. Additionally, the integrated mass spectrum (sum of all pixels) of the latter sample is seen in Fig. 6(i). The dwell time (data acquisition time per pixel) was chosen to be a couple of milliseconds to ensure multiple primary ion pulses in each pixel.

Fig. 6(c) represents a demagnification of the area shown in Fig. 6(b). It reveals the area of the previous imaging by a higher intensity, an effect that can be attributed to the removal of surface contaminants, surface roughening, or compositional changes induced by the ion beam.

For the secondary electron images in Fig. 6(d) an ion fluence of \(10^{14} \text{Ne}^+ \text{cm}^{-2}\) was applied whereas the SIMS measurement in Fig. 6(e-g, i) was done with \(3.8 \times 10^{12} \text{Ne}^+ \text{cm}^{-2}\) and in Fig. 6(h) with \(2.1 \times 10^{15} \text{Ne}^+ \text{cm}^{-2}\). The irradiated areas typically suffer from severe sample damage and in this case from sputtering in the exposed area and redeposition of material from sputtered particles. The latter would also result in a higher time or mass resolution due to the extension of the TOF. Therefore, the current setup was designed in a way that a later integration of a reflectron optics is easily possible.

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Contrary to the bulk signal, the molecular fragments exclusively originate from the first atomic layers and a high energy transfer scattering event is unlikely. Those particles can be emitted in a rather soft collision in the recoil cascade and therefore have a narrower energy distribution. A high energy collision would also result in higher fragmentation of these molecular fragments.

The mass resolution for bulk components can be increased by using a higher acceleration voltage for the secondary ions to reduce the relative ion energy spread. However, this would require a custom sample holder that can be biased to more than ±500 V. Alternatively, one could use a conventional reflection TOF design to compensate for the energy spread of sputtered particles. The latter would also result in a higher time or mass resolution due to the extension of the TOF. Therefore, the current setup was designed in a way that a later integration of a reflectron optics is easily possible.
Figure 6: Images of a transmission electron microscope grid as generated by a 25 keV Ne\(^+\) beam (a-c) (1024\(\times\)1024 pixels). The contrast is generated by secondary electron yield (a) and the positive secondary ion yield (b,c). Secondary electron image, ablation in exposed areas and sputter redeposition close by is indicated by green arrows (d), SIMS element maps (e-g) and integrated SIMS spectrum (i) of a NaCl micro-crystal and Na\(^+\) map of a NaCl nano-crystal (h). The measurements (e-i) were recorded with 25 keV Ne\(^+\), a pixel resolution of 256\(\times\)256, 150 ns pulses with 18 kHz repetition rate and 2.5 \(\mu\)A effective current. A 20 \(\mu\)m (e-g) / 700 nm (h) field of view, 15 ms (e-g) / 10 ms (h) dwell time per pixel and a total acquisition time of 16 min was used in (e-g) or rather 11 min in (h). The color of maps represents the number of counts per pixel (see color scale).
enhanced secondary ion yield from surface edges was also observed in other SIMS measurements in the HIM [31].

We thus demonstrated that sputtered particles can be extracted with a lateral resolution close to the fundamental limit of SIMS on flat samples, which has been estimated to be 3 nm (see Fig. 1). It should be emphasized that the lateral resolution alone does not take into account the sensitivity to certain ions. It will therefore not be possible to extract sufficient ions of each sample component from a sputter volume whose diameter is in the order of the lateral resolution. Therefore, highest lateral resolution is achieved exclusively for elements providing a high secondary ion yield.

Additionally, it has to be mentioned that our measurements were not carried out on a flat surface and are therefore not directly comparable with the simulation results. Furthermore, due to the sputtering process the surface topography changes continuously which will certainly influence the shape of edges during the data acquisition. Although we demonstrated highest lateral resolution of 7.7 nm, the ultimate resolution could not be achieved in this work since the low signal intensity and the quickly occurring sample damage hamper the precise focusing of the primary ion beam in the applied extraction field. In future work the influence of the extraction field on the primary ion beam will be studied to speed up the switching between normal secondary electron imaging and material analysis using SIMS.

4. Conclusions

TOF-SIMS was implemented in a HIM with a tilted and biased sample and a straight secondary ion extraction geometry. The implemented setup was simulated with IBSimu, optimized for a high efficiency using an evolutionary algorithm and experimentally studied on various samples. High transmission, a mass resolution of 0.3 u and 8 nm edge resolution have been demonstrated.

Sample damage and detection limits which are a function of the sputtered volume used during the analysis of nano structures are a fundamental limitation of sputtering based analysis methods in particular for the low amount of available sample material. However, with the demonstrated mass resolution and the resulting ability to separate isotopes for light elements in combination with the record lateral reso-
lution give the method a large potential for material analysis in life sciences, material science and other research fields.

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References


